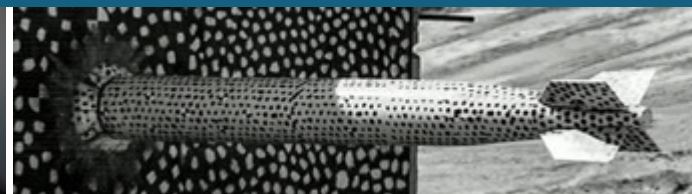
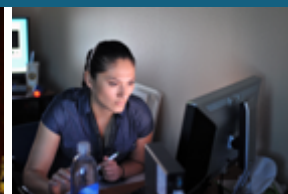
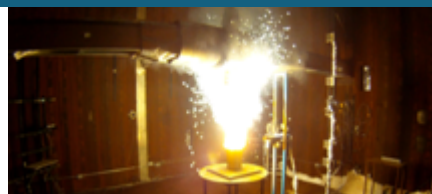




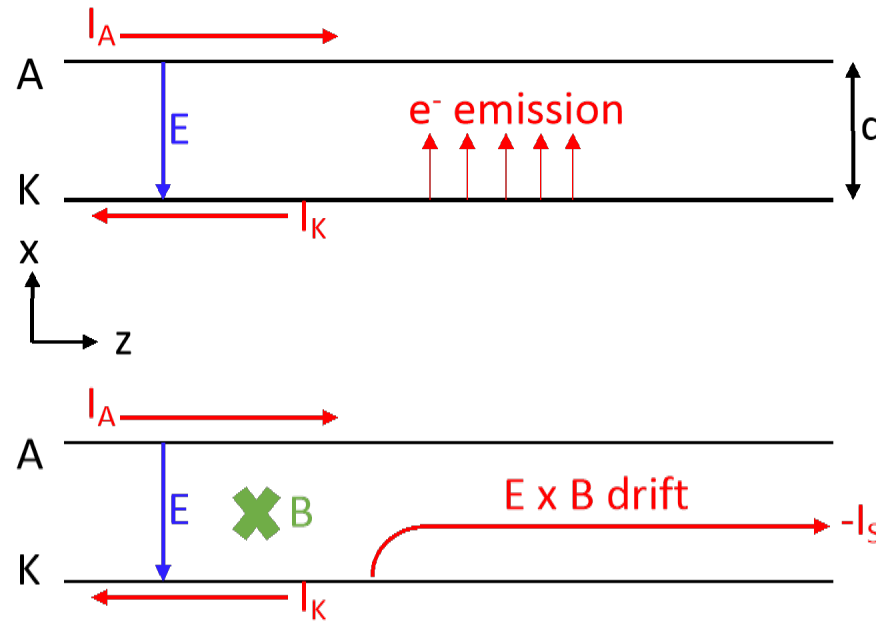
Secondary Ion Generation in an 18MV, 650kA Bremsstrahlung Diode



Authors:

Troy Powell, Adam Darr, Keith Cartwright

Intro: Magnetic Insulation



Magnetic (Hull) cutoff (classical)[1]:

$$B_H = \sqrt{\frac{2mV}{ed^2} + \left[\frac{mv_0}{ed}\right]^2}$$

Hull cutoff (relativistic)[2]:

$$\left(\frac{eB_H d}{mc}\right)^2 = \frac{2eV}{mc^2} + \left(\frac{eV}{mc^2}\right)^2$$

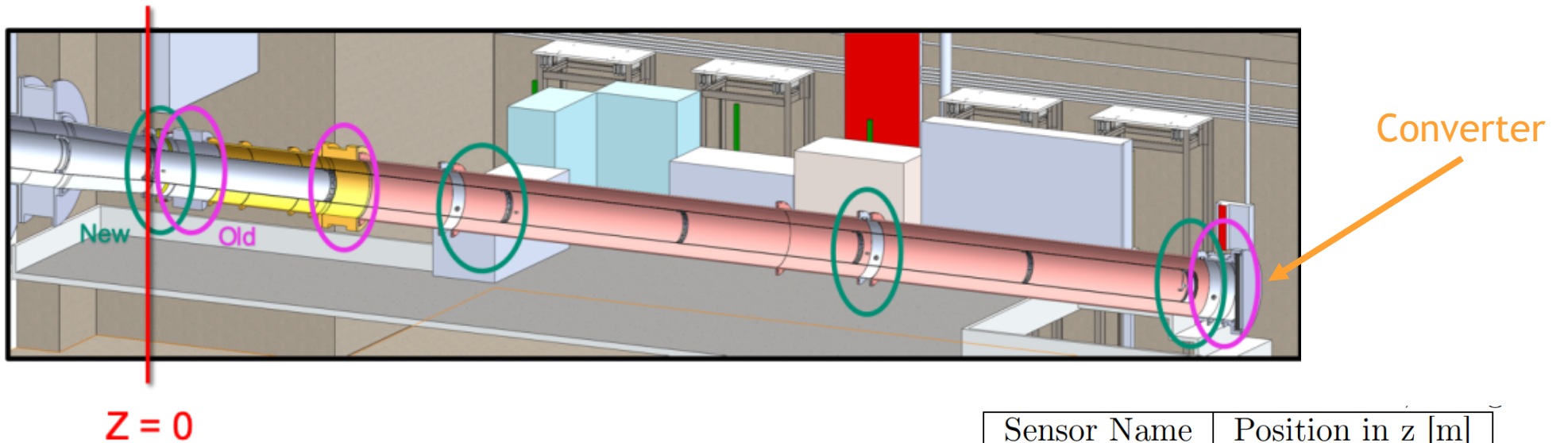
Magnetically Insulated Transmission Line (MITL)
Voltage[3]:

$$V = Z_0 \sqrt{I_A^2 - I_K^2} - \frac{mc^2}{2e} \frac{I_A^2 - I_K^2}{I_K^2}$$

[1]: A. W. Hull, "The effect of a uniform magnetic field on the motion of electrons between coaxial cylinders.," Phys. Rev, vol. 18, pp. 31–57, Jul 1921.

[2]: R. V. Lovelace and E. Ott, "Theory of magnetic insulation," The Physics of Fluids, vol. 17, p. 1263, 1974.

[3]: C. W. Mendel, M. E. Savage, D. M. Zagar, W. W. Simpson, and T. W. Grasser, "Experiments on a current-toggled plasma opening switch," Journal of Applied Physics, vol. 71, April 1992.



Use constant impedance

Maintain R_A/R_K ratio constant

Cathode was a feat of mechanical engineering

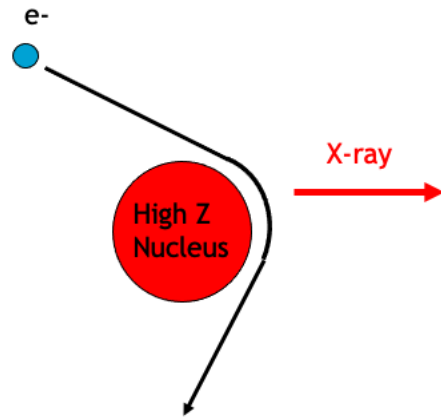
$$Z_0 = \frac{1}{2\pi} \sqrt{\frac{\mu}{\epsilon}} \ln \left(\frac{R}{r} \right)$$

Sensor Name	Position in z [m]
XAB1	0.072
XKB1	0.146
IAS1	0.245
IAS2	2.219
IAS3	2.58
XKB3	8.825
XAB3	8.861
XKB4	12.667
XAB4	13.064
IAS4	13.337
IAS5	13.379

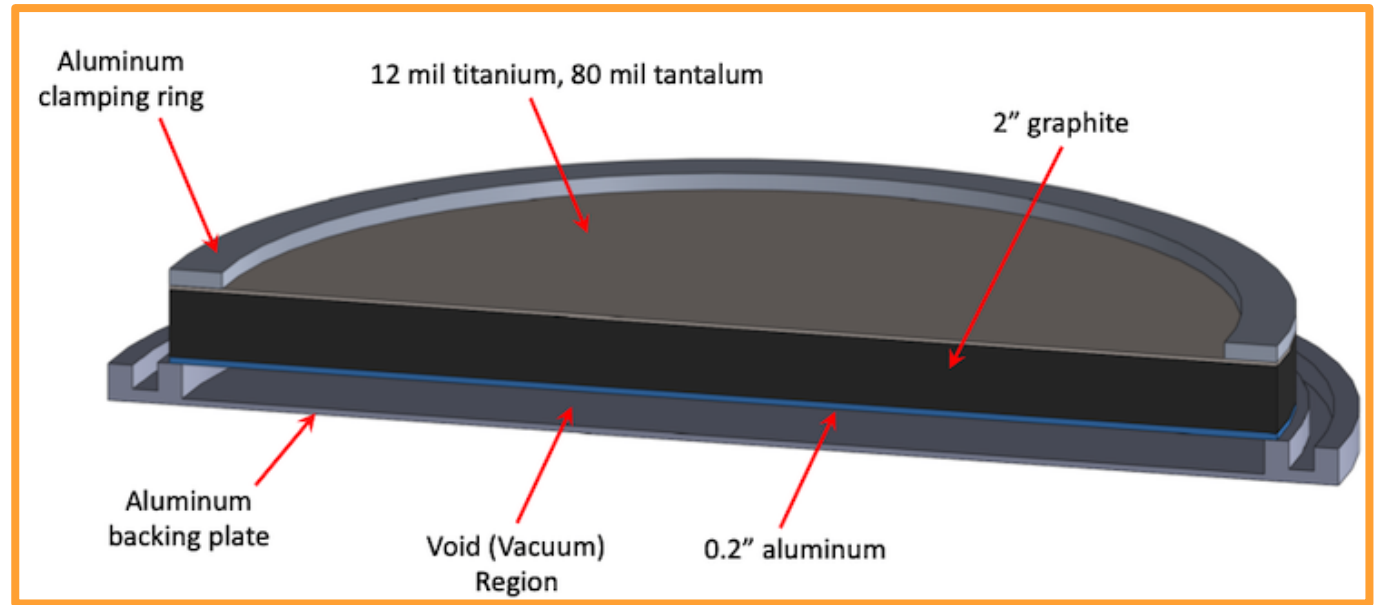
Intro: Bremsstrahlung



Bremsstrahlung “braking radiation”

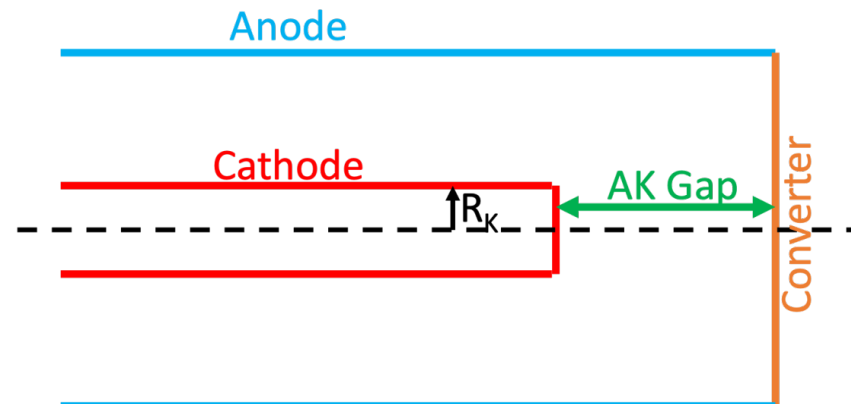


Converter



Bremsstrahlung diode dose optimization

- Diode geometry
- Converter pack



Theory: Self-Limited MITL Current

Start with Mendel. We want $f_{SL} = Z_0/Z_{flow}$
 Pointon [1] solved this numerically, and
 here we solve it analytically

$$V = Z_0 \sqrt{I_A^2 - I_K^2} - \frac{mc^2}{2e} \frac{I_A^2 - I_K^2}{I_K^2}$$

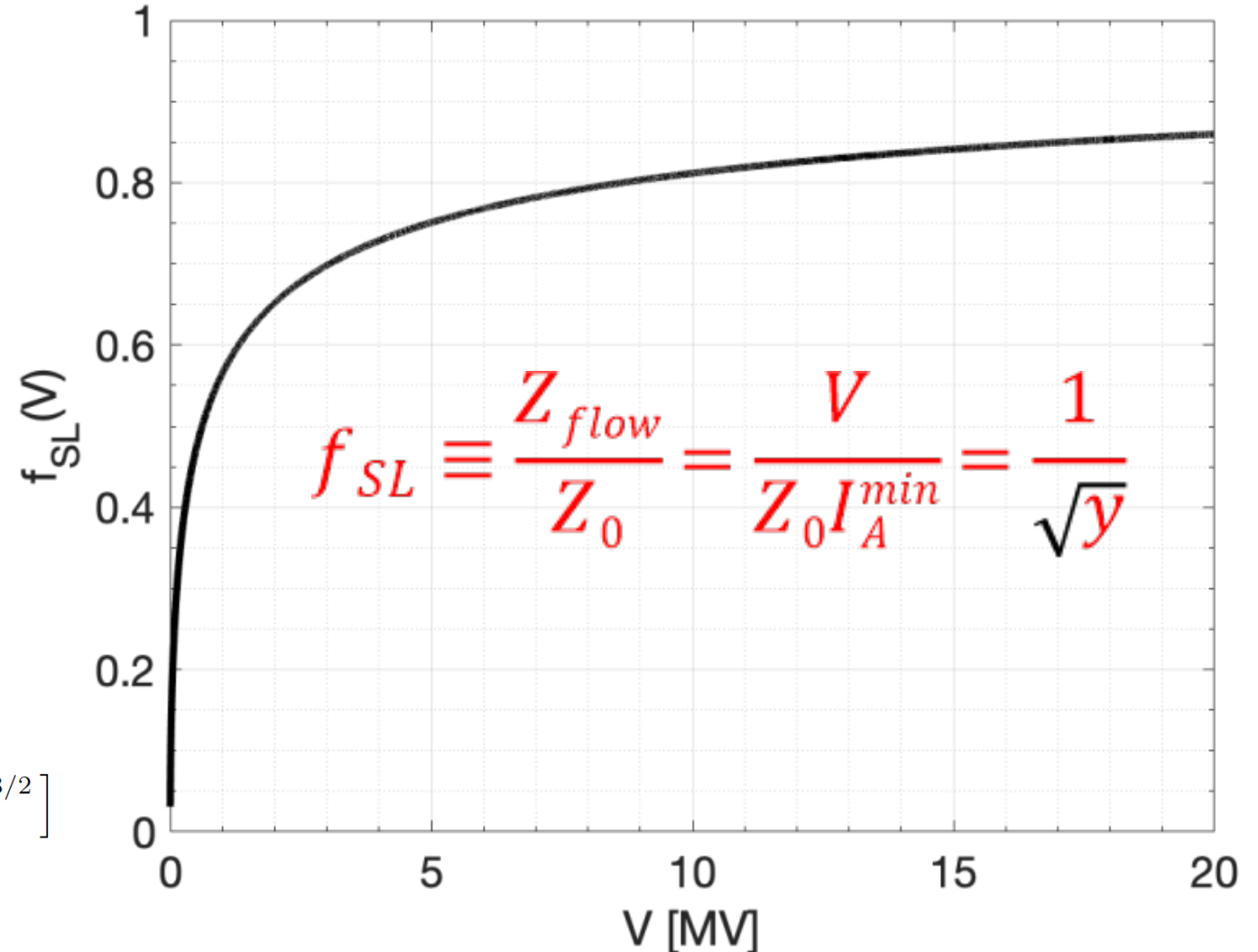
Nondimensionalize.

$$y = \frac{Z_0^2 I_A^2}{V^2}; x = \frac{Z_0^2 I_K^2}{V^2}; \kappa = \frac{mc^2}{2eV}$$

Optimize and solve for analytic $y(\kappa)$.

$$y = \frac{1}{32\kappa^2} \left[32\kappa + 6\alpha\kappa^{3/2}(\kappa + 2)^2 - 2\kappa^2(\kappa - 14)(3\kappa + 2) - \sqrt{\alpha\sqrt{\kappa}(\kappa + 2) - \kappa(\kappa + 6)} (\alpha\sqrt{\kappa}(\kappa + 2) - \kappa(\kappa - 10))^{3/2} \right]$$

$$\alpha = \sqrt{\kappa + 8}$$





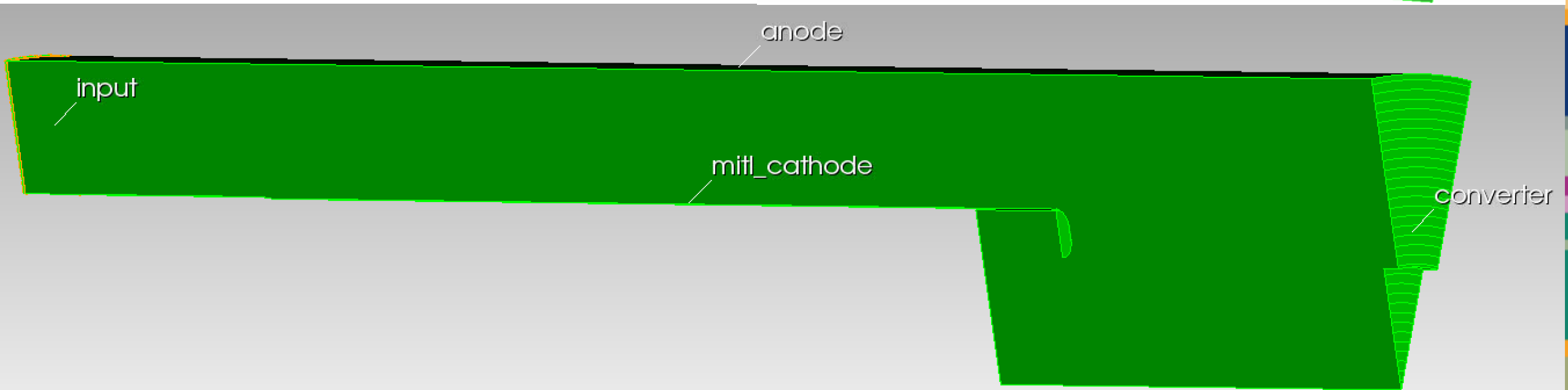
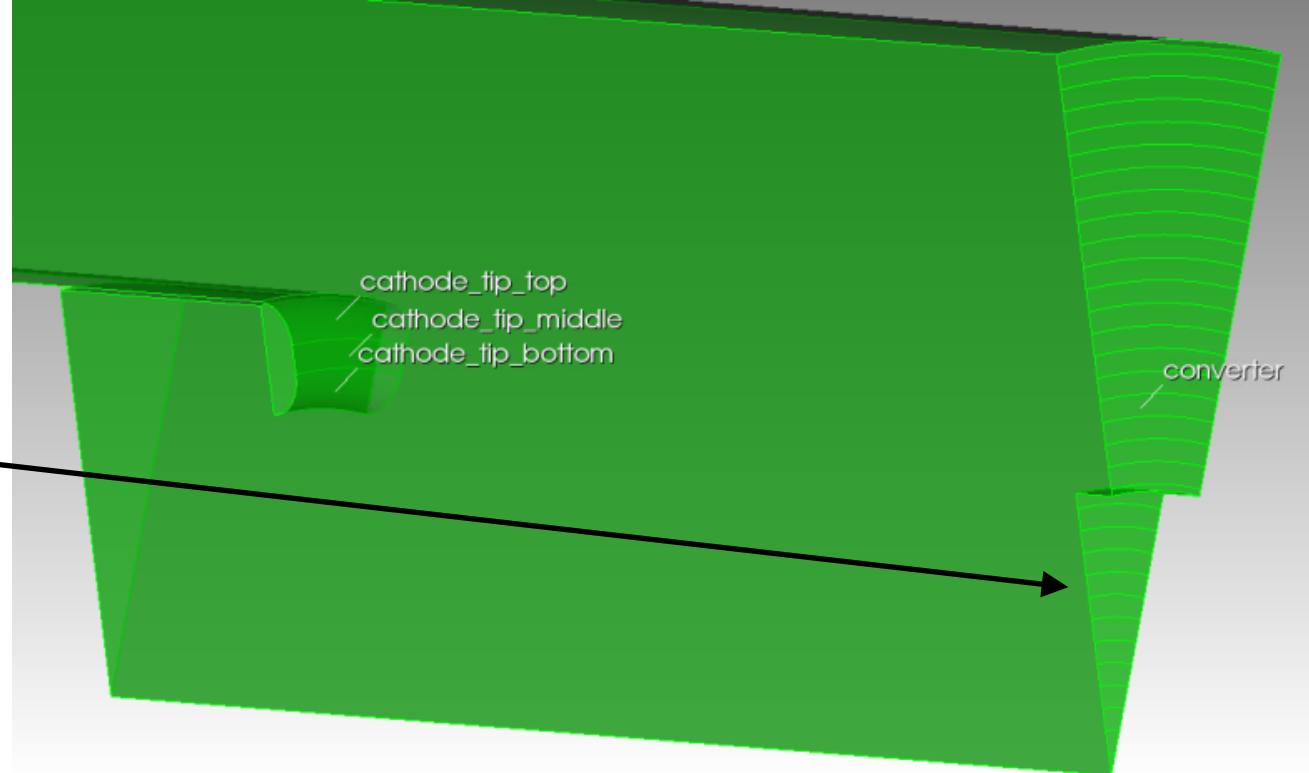
Simulating Shots 11132-36, 11146 in EMPIRE



Model

Wedge angle 22.5°

Graphite plug modeled with PEC



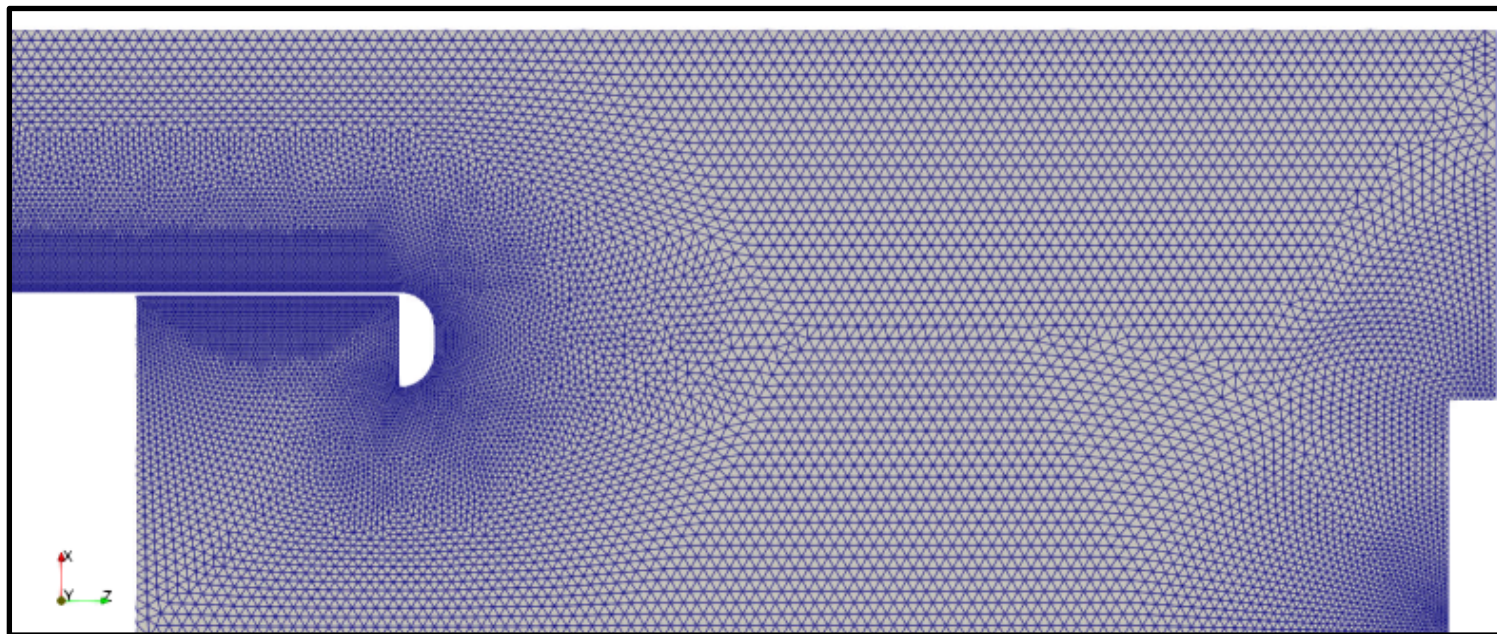
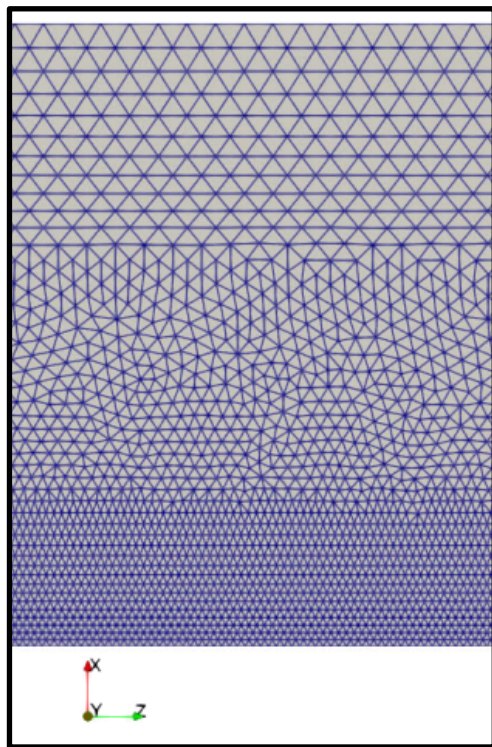
Resolution

$$dx_{\max} = (R_A - R_K)/20 = 0.705\text{cm}$$

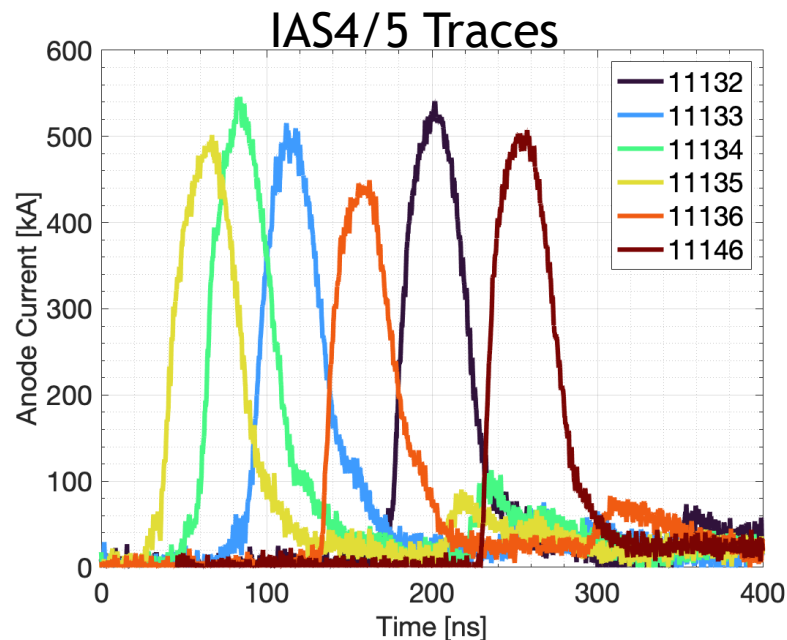
$$dx_{\text{cathode}} = 0.25 * dx_{\max} = 0.17625\text{cm}$$

$$dt = 2.0\text{ps}$$

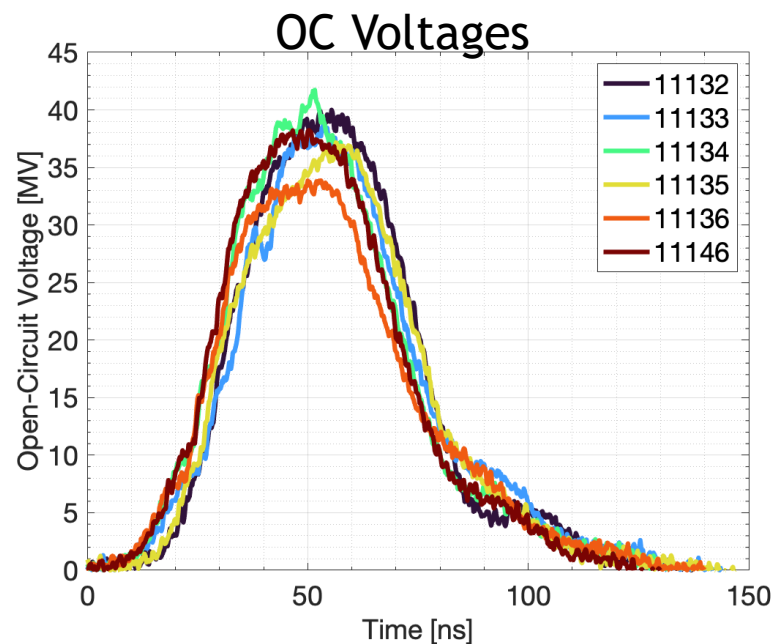
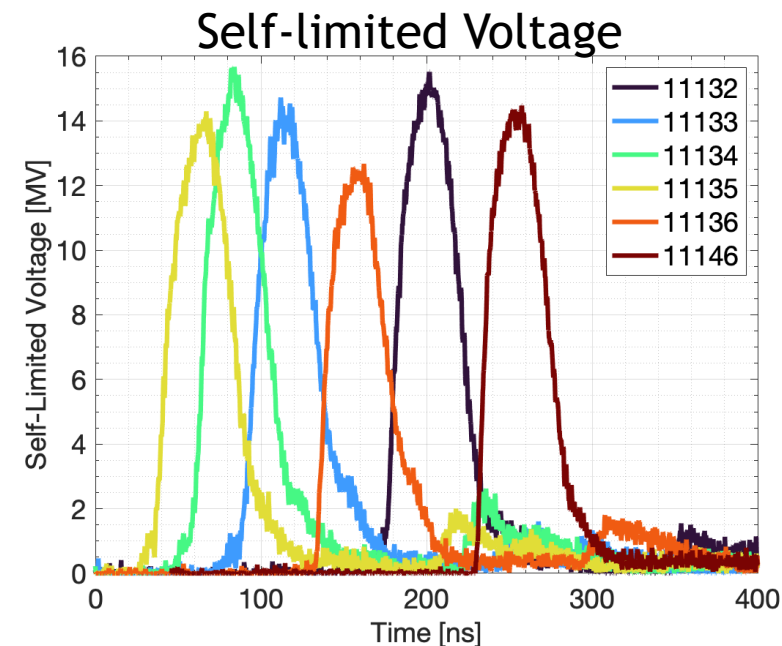
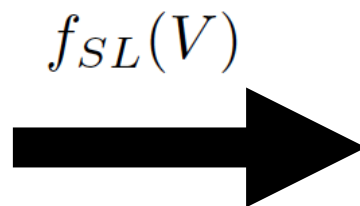
$$\text{CFL} = c * dt / dx = 0.085 - 0.34$$



9 Driving the Diode



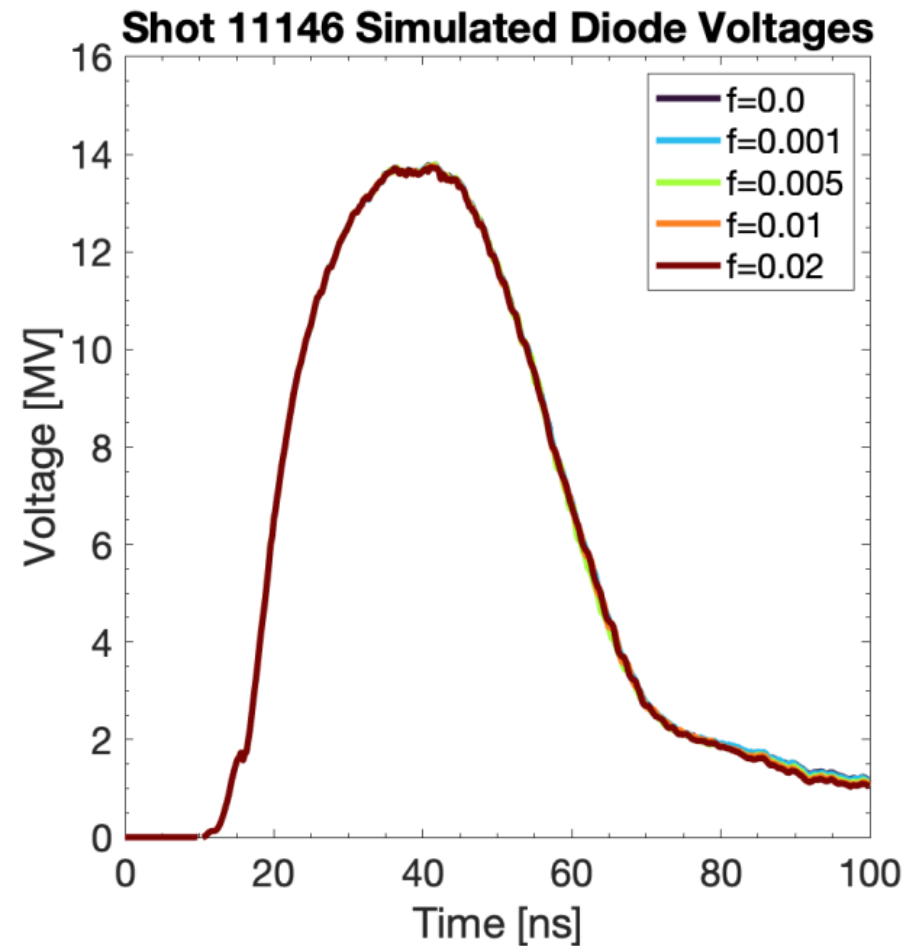
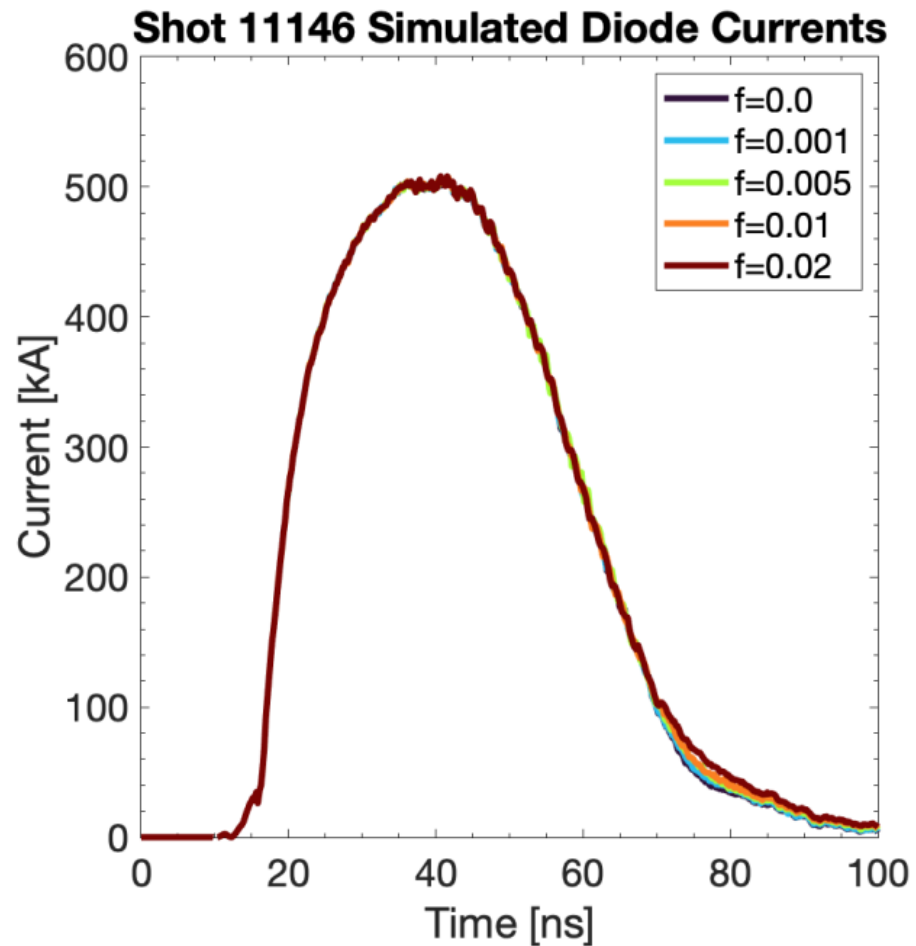
pulse arrival time is arbitrary



$V_{OC} = V_{SL} + Z_0 * I_A$
temporally aligned

Ion Effect on Diode Current

f = ion injection fraction



Killed electrons re-injected as ions with fraction f

Expect ions in the range of 0-2% due to results from Mercury [1]

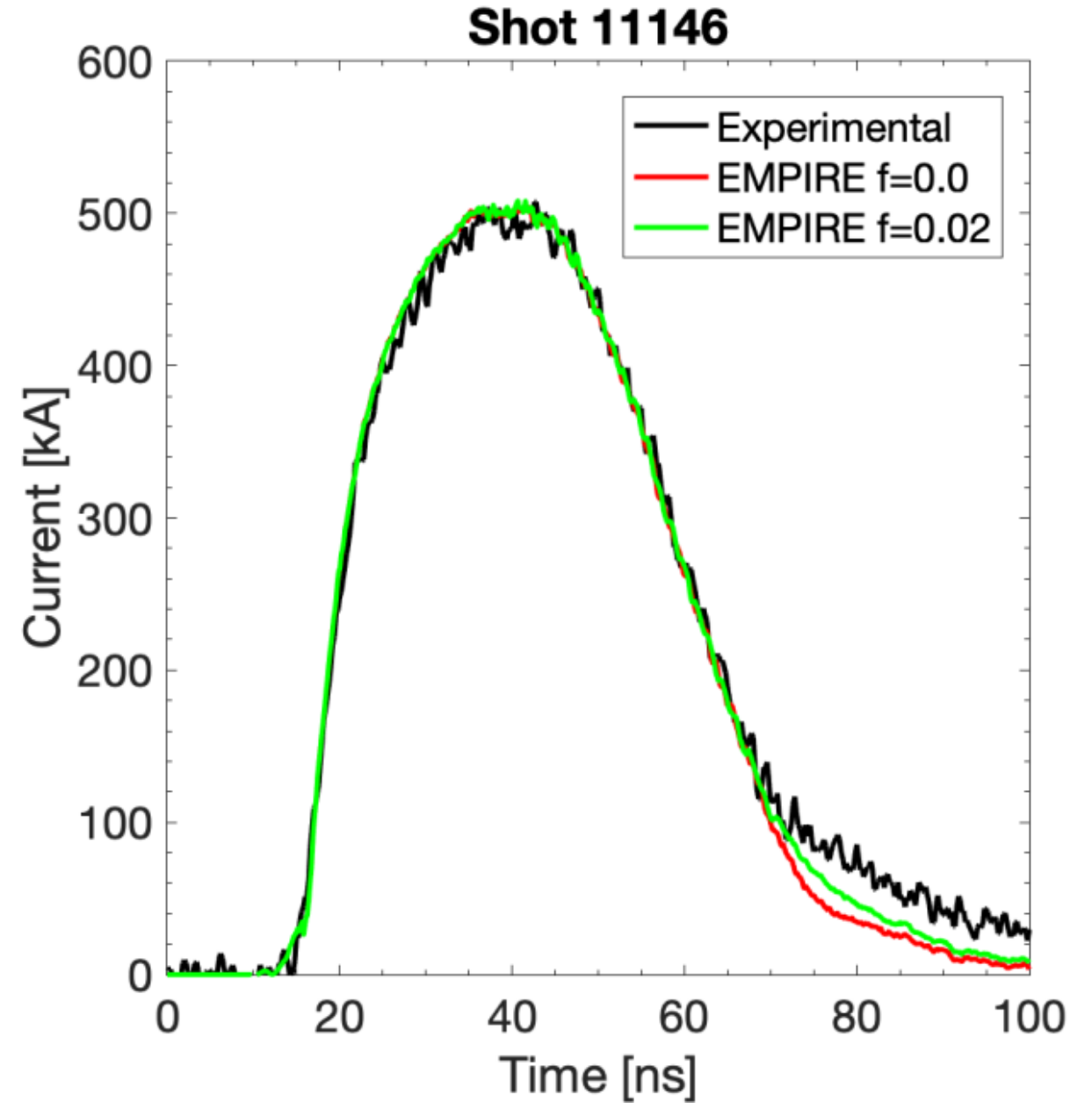
Ions only affect the tail of the pulse

Simulated Diode vs Theory - 11146



$f=0.02$ gave the closest agreement

- Future work: increase ions to match tail
- This is the largest fraction we have tried so far
- Increasing ions will impact dose profile

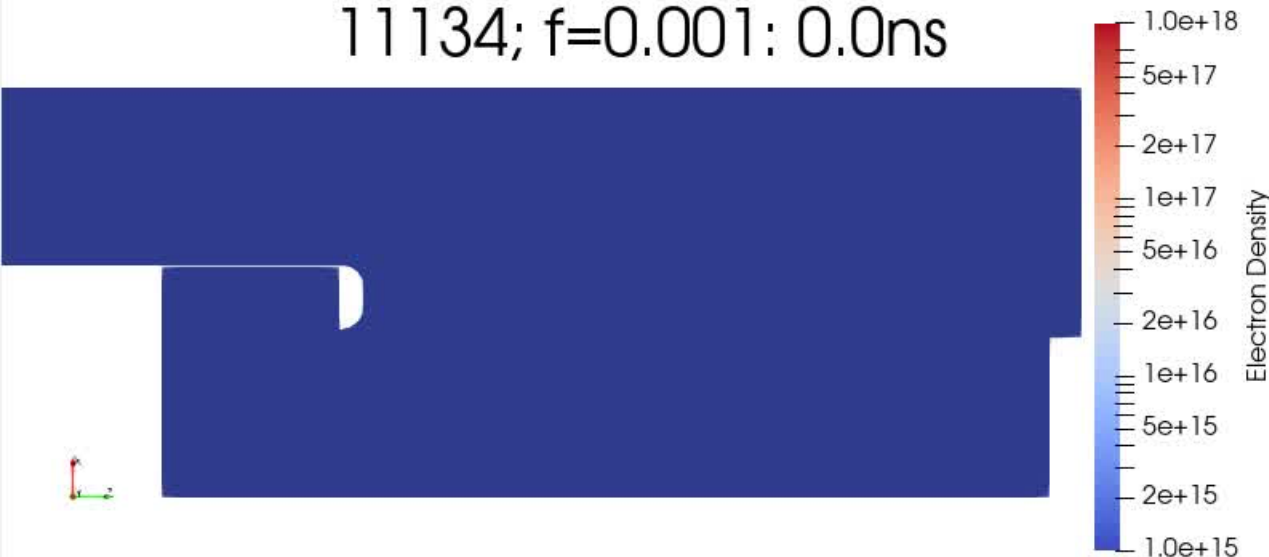




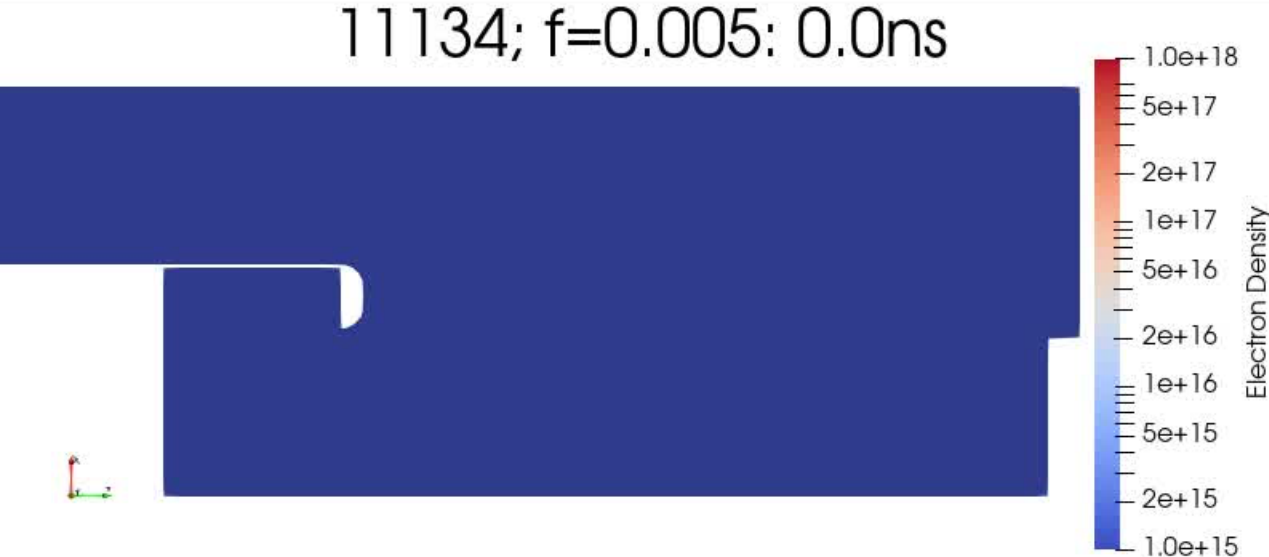
11134; $f=0.0$: 0.0ns



11134; $f=0.001$: 0.0ns



11134; $f=0.005$: 0.0ns



11134; $f=0.01$: 0.0ns



11136 electron flow

11136; $f=0.0$: 0.0ns11136; $f=0.001$: 0.0ns11136; $f=0.005$: 0.0ns11136; $f=0.01$: 0.0ns



Converter Modeling in ITS



Converter Geometry

1" Graphite plug (10" OD)

12 mil Ti (33.75" OD)

80 mil Ta

2" Graphite beamstop

3/16" Al clamping plate

1/2" Vacuum

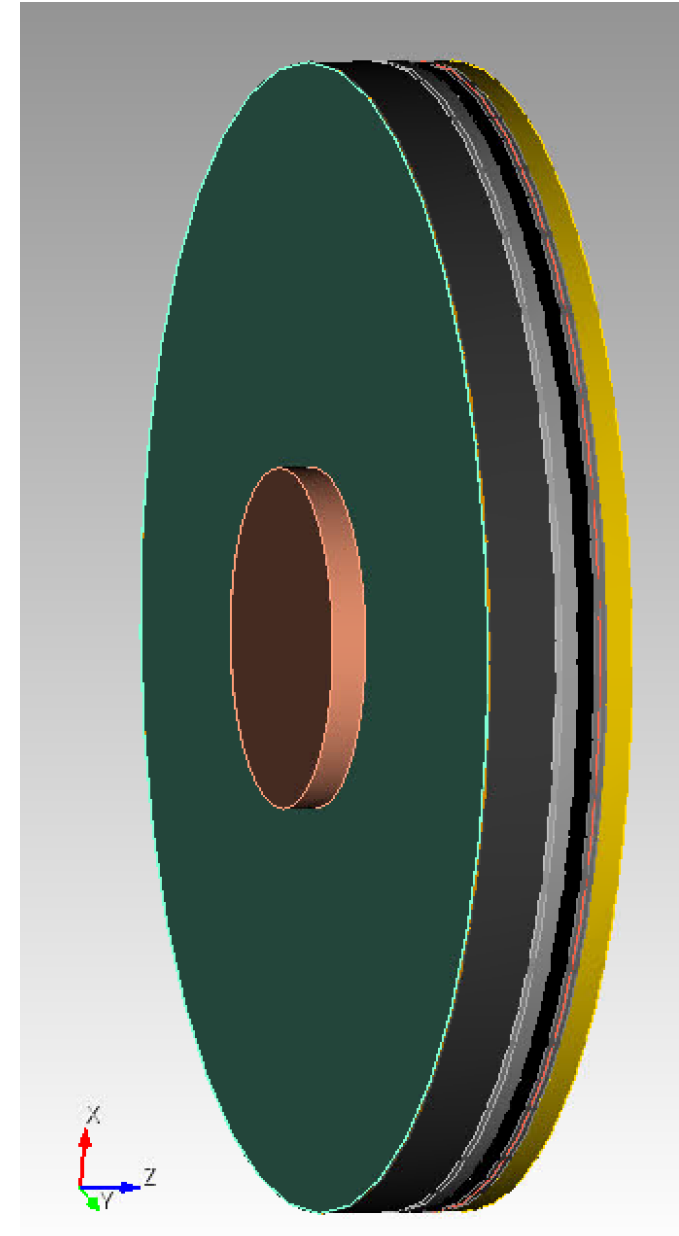
1/2" Al Faceplate

0.17" Al equilibrator (has Si, Mn, Fe, and Cu)

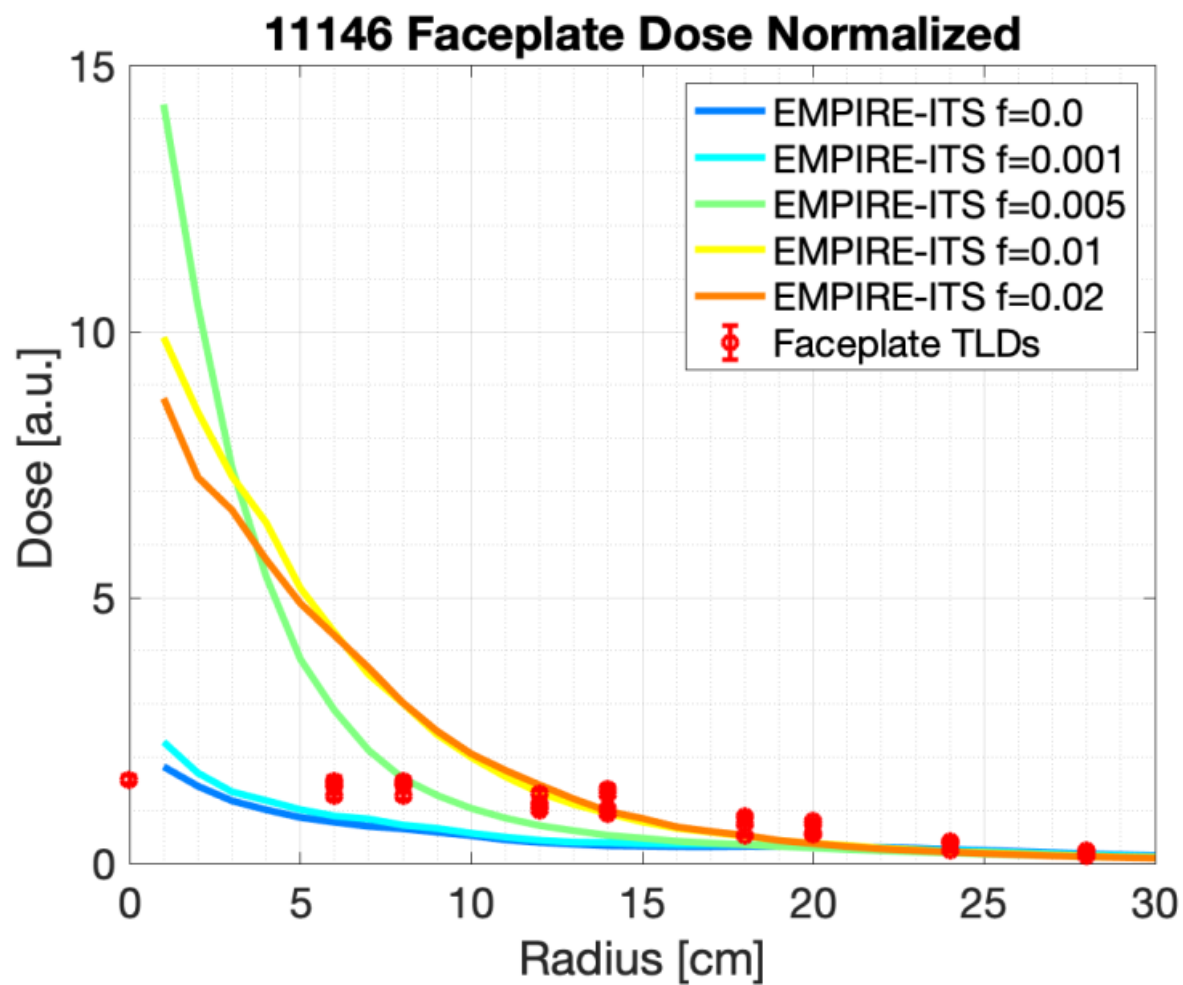
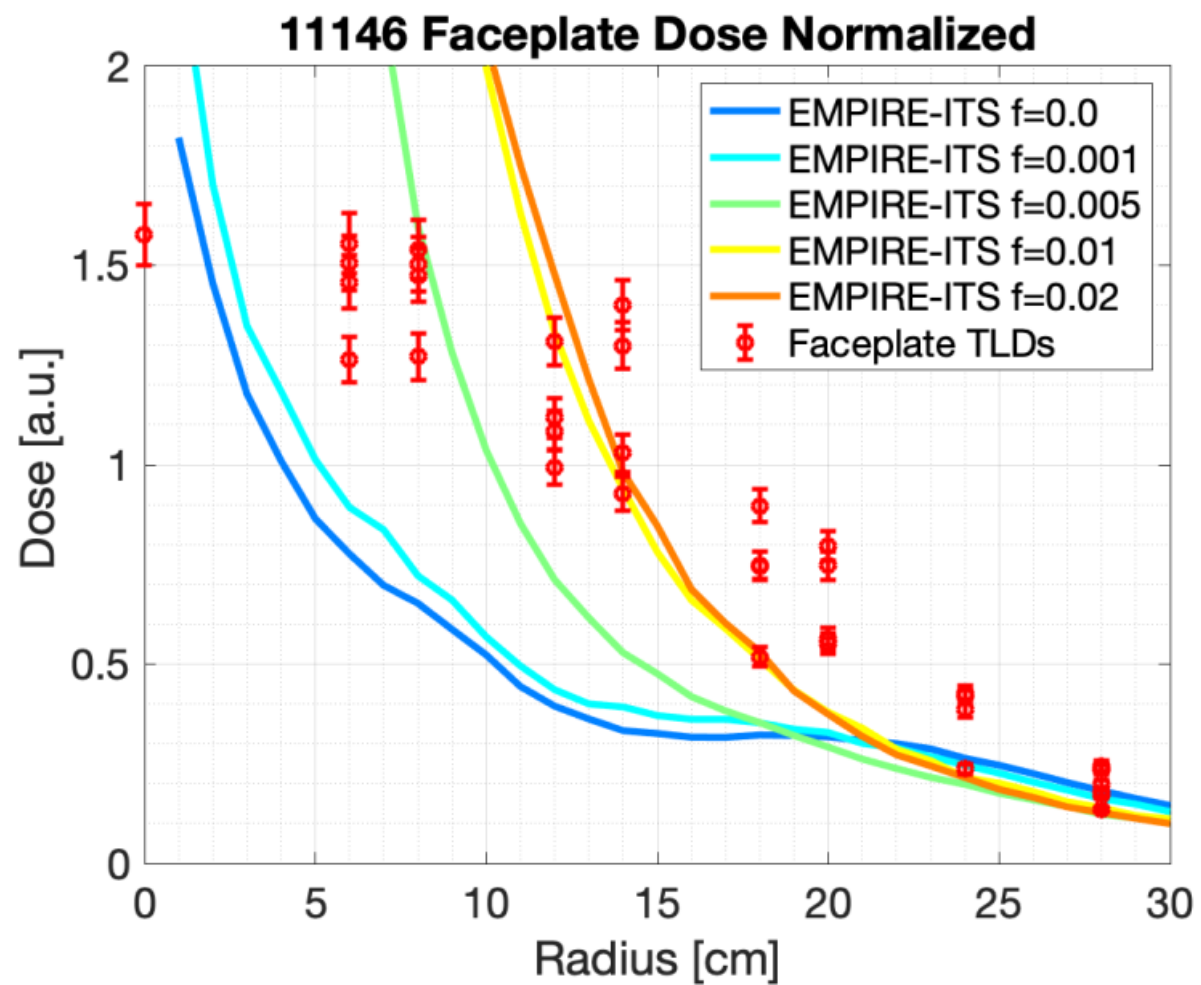
0.035" CaF_2

0.17" Al equilibrator

TLD-400



Shot 11146 Faceplate



Conclusions



Mendel's theory was used to interpret experimental sensor current into open-circuit simulation voltage waveform input

This workflow can be utilized to accurately simulate select shots

Even a small amount of ions barely changed the diode current, but drastically changed the diode flow pattern and the dose pattern

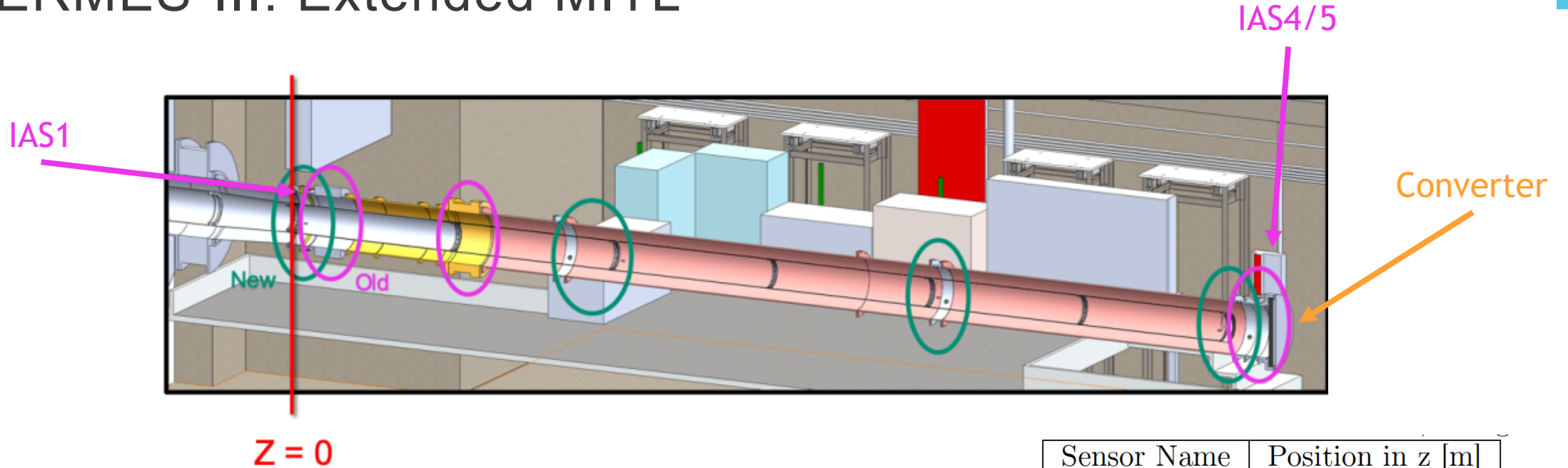
The EMPIRE-ITS workflow can be used to model and replicate Bremsstrahlung dose patterns for specific shots

- Future work: add in calibration factor to IAS5 traces
- Future work: increase ion injection fraction (to match tail)



HERMES-III Extended MITL Validation





Use constant impedance

Maintain R_A/R_K ratio constant

Cathode was a feat of mechanical engineering

$$Z_0 = \frac{1}{2\pi} \sqrt{\frac{\mu}{\epsilon}} \ln \left(\frac{R}{r} \right)$$

Sensor Name	Position in z [m]
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XKB3	8.825
XAB3	8.861
XKB4	12.667
XAB4	13.064
IAS4	13.337
IAS5	13.379

HERMES-III: IAS4/5 Calibration

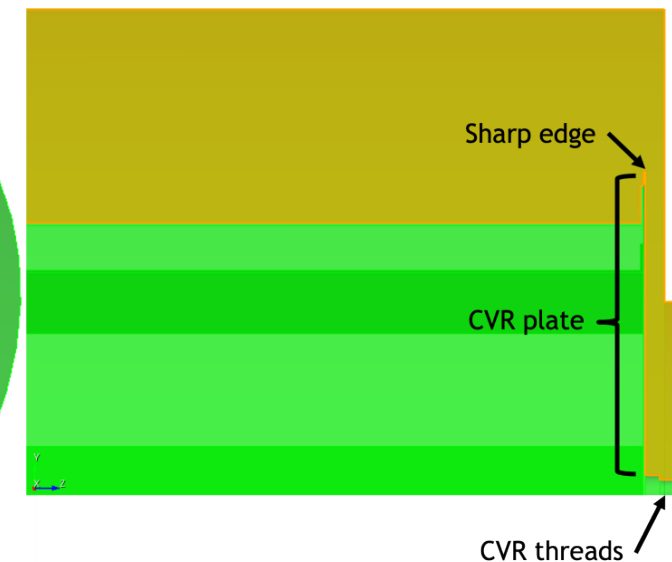
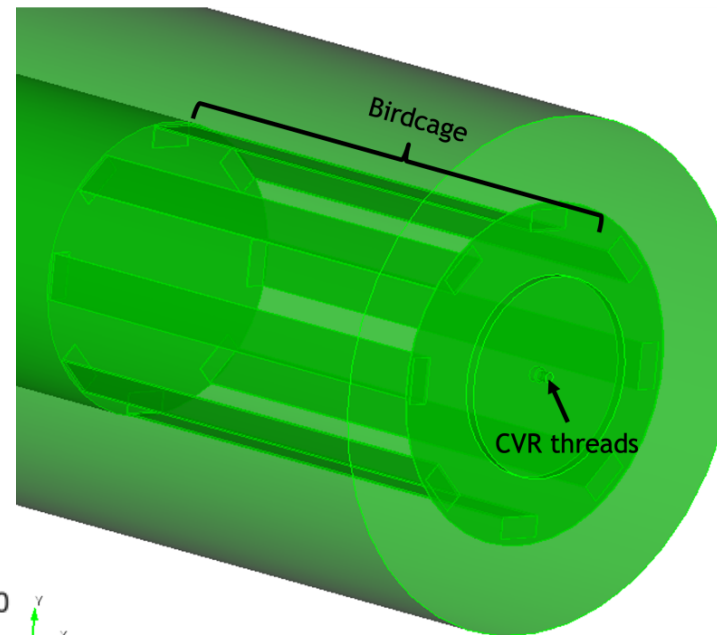
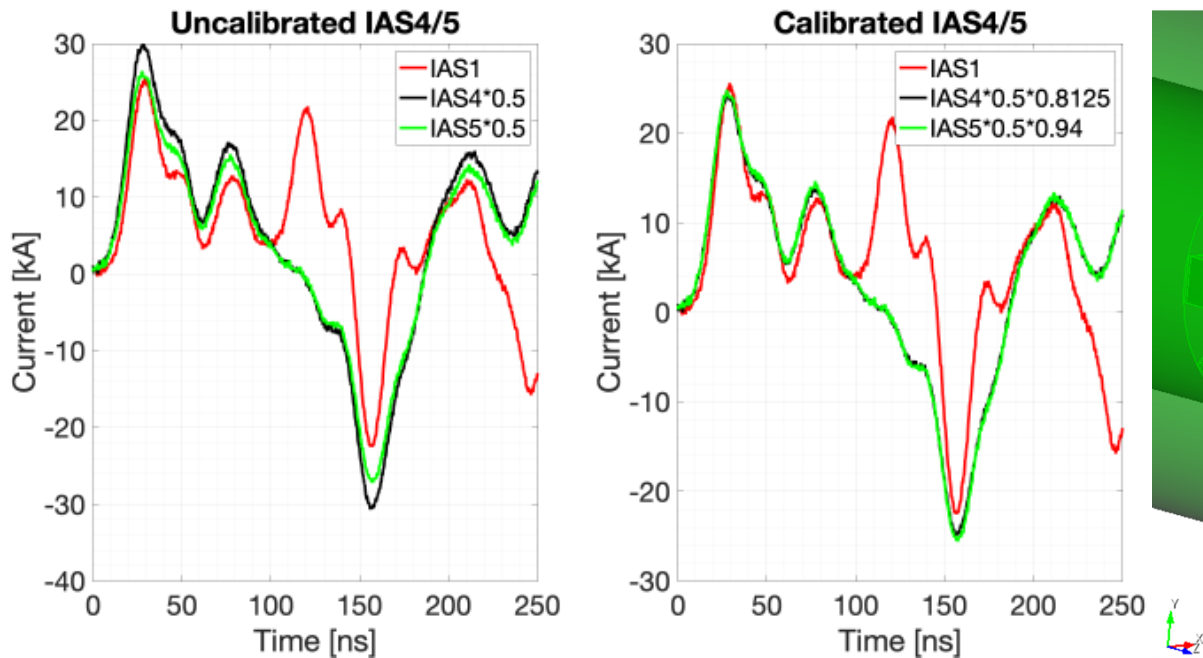


Short shots 11154 and 11155

Only first peaks of IAS4/5 calibrated to IAS1 (trusted legacy diagnostic)

Multiply IAS4 by 0.8125

Multiply IAS5 by 0.94

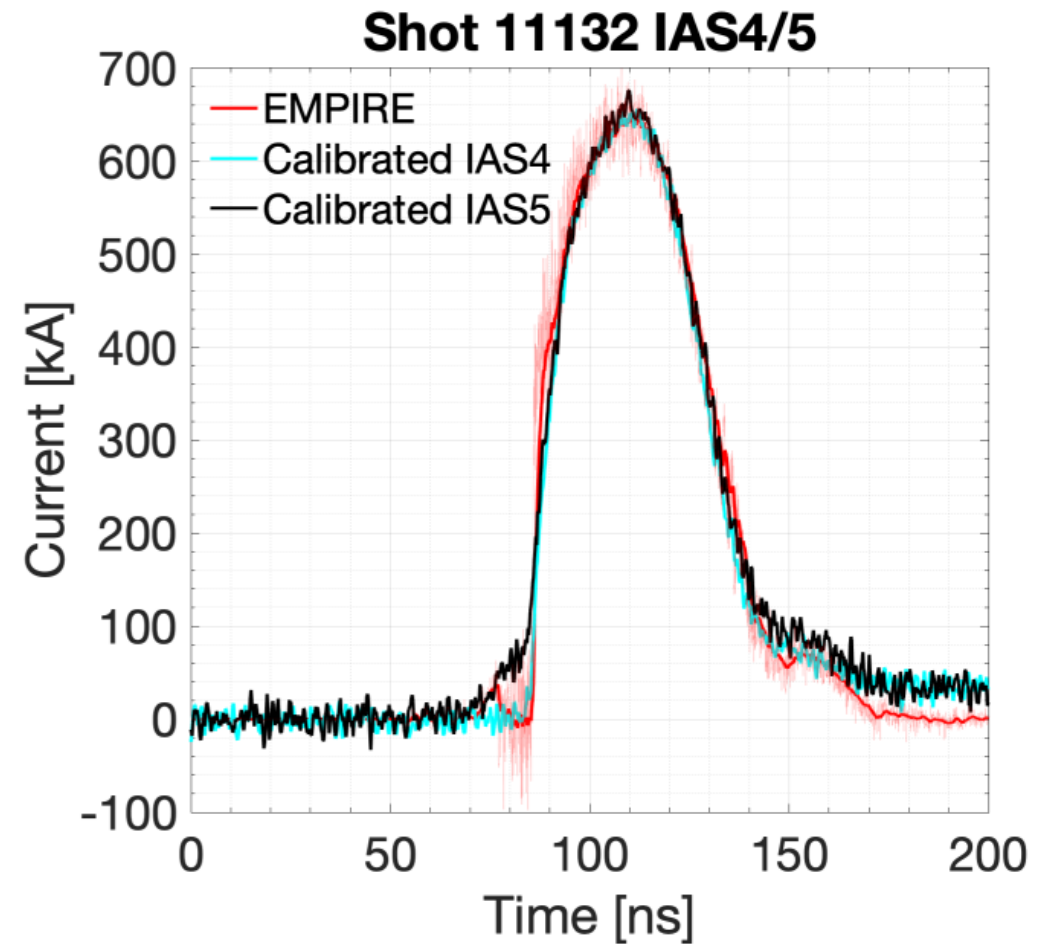
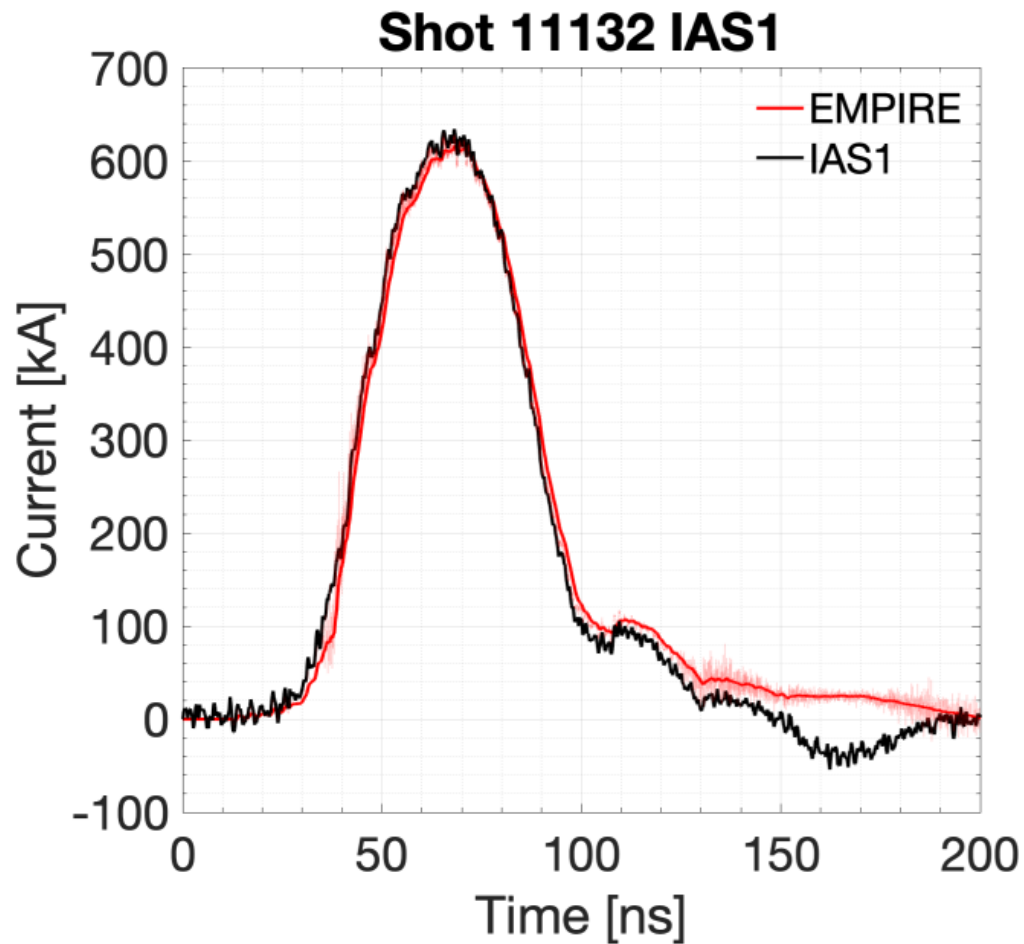


HERMES-III: Extended MITL Validation of shot 11132



Shots 11132-36 and 11146 used for validation

EMPIRE simulation driven with f_{SL} described earlier



Signals integrated from $t=0$ to 80ns after peak current

Simulation data points move left along isopotentials as the pulse rolls down the MITL

